

ABSTRACT

A method for manufacturing a glass substrate for an information recording medium includes a precision polishing step (S18) of performing
5 precision polishing on a main surface of a glass member using an acidic polishing liquid at pH 4 or less that contains colloidal silica, a first immersing step (S19) of performing immersion in a solution for 5 minutes or more after the precision polishing step (S18), and an ultrasonic cleaning step (S20) of
10 performing ultrasonic cleaning on the glass member after the first immersing step (S19). The glass member subjected to the precision polishing in the precision polishing step (S18) has a surface roughness Ra of 3.0 Å or less in a measurement area of 1 μm^2 , and the pH of the solution used in the first immersing step is 6.5 or more to 8.5 or less.